


<b>Search Notes</b>  	<b>Application/Control No.</b>  10500737	<b>Applicant(s)/Patent Under Reexamination</b>  IMAMURA ET AL.
	<b>Examiner</b>  Liao, Diana J	<b>Art Unit</b>  4116

<b>SEARCHED</b>			
<b>Class</b>	<b>Subclass</b>	<b>Date</b>	<b>Examiner</b>
423	325, 335	10/16/2007	DJL

<b>SEARCH NOTES</b>		
<b>Search Notes</b>	<b>Date</b>	<b>Examiner</b>
Inventor search done in eDAN	10/16/2007	DJL
Databases used: EAST, Google Scholar, STN	10/16/2007	DJL

<b>INTERFERENCE SEARCH</b>			
<b>Class</b>	<b>Subclass</b>	<b>Date</b>	<b>Examiner</b>